IFW

Application No. 10/722, 729 Amendment Dated March 29, 2005

PATENT

IN THE UNITED STATES PATEN	T AND TRADEMARK OFFICE
In re the application of:	
)	Examiner: G.B.M. Nguyen
Bright et al.	Crosse Ant Huite 2722
Application No: 10/722,729)	Group Art Unit: 3723
)	Date: March 29, 2005
Filed: November 25, 2003	
)	-
For: APPARATUS FOR CONTROLLING)	
WAFER TEMPERATURE IN CHEMICAL)	•
MECHANICAL POLISHING (as amended))	

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, Box 1450, Alexandria, VA 22313-1450, on March 29, 2005.

Signed:

Kay Harlow

AMENDMENT TO TITLE

Mail Stop Non-Fee Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Applicants are hereby submitting this Amendment to correct the title as listed on Page 1 of the specification, as filed.

The amendment appears on page 2 of this document.

Remarks appear on page 3 of this document.

Docket No: LAM2P318C

Application No. 10/722, 729 Amendment Dated March 29, 2005

On page 1, line 1 of the application, please amend the title to read as follows:

"APPARATUS FOR CONTROLLING WAFER TEMPERATURE IN CHEMICAL MECHANICAL POLISHING"

Docket No: LAM2P318C Page 2 of 3